# Novel Experimental Setup to Study the Magneto-Resistance of Semiconductors and Its Industrial Application

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Abstract-Since its invention in the turn of 20th century, semiconductors have always riddled the minds of contemporary science. The various properties of the semiconductors have been studied using spectroscopy, Hall Effect experiment or simple measurement methods under different conditions. The behavior observed has led to a different aspect and hence a different application. The aim of this paper is to study the properties of a semi-conductor bar specially the magneto-resistance, carrier concentration, Energy band gap and the effect of magnetic field on Hall coefficient using a new experimental setup and also discuss its application. Another objective of this paper has been validating the Drude's Model and proposing a solution to the Hall Effect drawback. The design can be used as a replacement to the Hall Effect experiment where as it incorporates the magnetic field's effect for the Hall co-efficient. This experiment employs only magnetic field to determine the magneto resistance unlike Hall Effect where along with magnetic field electric field is also used.

*Index Terms*—Experimental set-up, hall-effect, drude's model, magneto-resistance

#### I. INTRODUCTION

The independent electron model or the free electron model has been the cornerstone for semiconductor studies [1] and applying the concepts of those models the various phenomenons of semi-conductors [1], [2] like Hall Effect, carrier density, band gap measurement is being studied. Hall Effect experiment had been another very significant contribution to studies of semiconductor. Employing the Hall Effect, magneto-resistance [3] of materials is analyzed and inferred as only dependent on carrier density of the material, whereas, it is experimentally observed, that not only carrier concentration but it depends on temperature and the magnetic field also [1]. This paper discusses a new experimental setup which takes into account the behavior of a semiconductor under a magnetic field when it is subjected to a mechanical force. Unlike Hall Effect experiment where applied electric field and applied magnetic field are perpendicular to each other, in this experimental set-up we are not applying any electric field, thereby employing only one source of electrical field, i.e. the electrical field produced due to the motion of free electrons. Thus, any other force on electrons is avoided, but the applied external magnetic and the internal atomic and molecular forces. This concept can not only measure the most important aspect of semiconductor, like, number of conduction band electrons, energy band gap, but

magneto-resistance and dependence of it on the factors of external magnetic field also. Drude's model has been used to analyze the system so far.

## II. DESIGN OF EXPERIMENTAL SETUP

The experimental setup consists of a semiconductor bar (of length '2L' and cross-sectional area 'A') mounted on the shaft of a motor, a grounded metal ring supported on tripod stand and a magnetic field. Fig (1a) and Fig (1b) shows the front view and the top view of the experimental setup. The electric motor has a metal shaft on which the semiconductor bar is mounted. The metal shaft acts as a point for measuring the voltage. The other point for measuring the voltage is the grounded metal ring. The semiconductor bar is rotated in a magnetic field (B) pointing downwards in Fig (1a).



Fig. 1b. Top view of the experimental setup

## III. CALCULATION AND ANALYSIS

### A. Open Circuit Condition (Case 1)

By open circuit it is meant that the metal shaft is insulated from the semiconductor bar and the ring supports are insulated as well. Thus, the force from the magnetic field will

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drive the electrons to generate an electric field internally and an emf can be observed with the help of figure shown.



Fig. 2. Open circuit condition

The open circuit condition can be equivalent to a chemical cell where the emf is generated from the chemical energy. Similar to the Hall Effect where the components of velocity of electrons due to random motion cancel each other over a period of time [3], [4], here also we employ the consideration <sup>[8]</sup>. Thus the electrons have velocity due to angular motion. If the angular velocity is  $\omega$ , then the velocity of an electron at a distance x is

 $|v| = \omega x;$ 

The electrons will start to move from the end (due to highest velocity) and as they vacate their position there will be ions which will attract the next layer of electrons. Thus, the next layer of electrons are pushed by the magnetic force and pulled by the local electric field.

$$-e (dV/dx) = e\omega xB \hat{i}$$
$$E_i = (-dV/dx) = -\omega xB \hat{i}$$

The force on one electron will be due to this local electric field  $(E_i)$  and external magnetic field (B)

$$|F_x| = 2e\omega xB$$

We have two possibilities now-

SUBCASE 1: If the valance band electrons do not come to the conduction band then the central position gradually will be left out of electrons and only ions will be there. These ions will be positively charged and hence will pull the electrons which were moving outward previously. Due to this new electric field all the electrons will cease their motion and come to equilibrium.

At the beginning let the voltage be  $V_i$ 

$$e(dV/dx) = e\omega xB$$
  
or,  $dV = \omega xB dx$   
 $\Delta V = \int dV = \omega BL^{2}/2$ 

And finally when all the electrons cease their motion it can be considered equivalent to an equipotential wire where at each point the voltage is  $V_f$ . This final potential rise  $V_f$  is due to the work done by the magnetic field and the internal electric field. Thus the work done by the force  $F_x$ , *i*f carrier density is n-

$$\int_0^L F_x(L-x)(nAdx) = e\omega nABL^3/3$$

This is equal to the voltage rise, thus-

$$e\omega nABL^3/3 = en(AL)V_f$$
  
or,  $V_f = \omega BL^2/3$ 

SUBCASE 2: If n' number of electrons per unit volume get energy from the magnetic field and jump from valance band to conduction band then in that case the initial voltage will be exactly like previous case but the final voltage will be different. In this case the work done by  $F_x$  is –

$$\int_0^L F_x(L-x)(nAdx) + n' E_g (AL)$$
  
This is again equal to voltage rise-

$$\int_0^L F_x(L-x)(nAdx) + n \, i \, E_g \, (AL) = en(AL)V_f$$
$$n \, i E_g = en \left[(\omega BL^2/3) - V_f\right]$$

if n'=0 then  $V_f = \omega BL^2/3$  else  $V_f = \omega BL^2/3$ -  $(n'E_g/ne)$ Thus the final voltage will be less by a factor  $(n'E_g/ne)$ 



g. 5. Variation of voltage along the length from the shaf Solid line:  $V_i$  - SUBCASE1 (CASE 1) Dashed Line:  $V_f$  - SUBCASE 1(CASE 1) Bold Solid Line:  $V_f$  - SUBCASE 2 (CASE 1)

B. Closed Circuit Condition (Case 2)



Fig. 4. The closed circuit condition

For this condition shaft will be connected to the bar and supports for the metallic ring will be conducting as well. From the shaft a conducting wire is grounded through a microammeter as shown in the figure.

Now from the figure it can be easily said that

$$I = \Delta V / (R_b + R_c)$$

where,  $R_b$ =magneto-resistance

 $R_c$  = total contact resistance

$$(R_b + R_c) = \Delta V/I$$

Now as the gap created by the mobile conduction band electrons are filled from the metallic shaft, thus

$$\Delta V = \omega B L^2 / 2$$

And the current will be

I = n(AL)e/twhere t is the time over which the bar has been rotated. Thus,-

 $(R_b + R_c) = \omega BLt/(2nAe)$ 

Or, Hall Co-efficient is proportional to  $\omega Bt/2ne$ 

Now it can be seen that magneto-resistance not only depends on the carrier concentration n but also the magnetic field B. The magnetic field affects the resistance along with  $\omega$ . Thus if angular momentum is associated along with Drude's linear motion then the effect of magnetic field on Hall co-efficient can be analysed.

### IV. APPLICATION

1) If we replace the semiconducting bar with a conducting one then the  $i_{av}$  will be greater. If we attach this type of arrangement with the axle of a locomotive and set the load as headlight, stereo system or fan there will not be any need of battery. But we have to conserve charge otherwise these systems will not work, when the locomotive is at rest. This will be really useful in trains as there are many more wheels and many lights, fans and ACs to run.



Fig. 5. Connection in locomotive application

- 2) We can replace the semiconductor by n-type or p-type and measure N for them.
- 3) Finding N' i.e. no. of electrons transferred to conduction band per unit volume and N' vs temperature.
- 4) We can calculate  $E_q$  for a semiconductor for a special case.

5) It can also be used as a viscosity sensor<sup>[5]</sup>, where the bar will be rotated in the material and the current or the voltage will give the measure of viscosity.

#### V. CONCLUSION

The new experimental setup discussed in the paper not only helps in the characterization of properties of semiconductor but also takes into account several new aspects. This also leads to easy measurement of properties without complicated procedures. The novel experimental setup can also be used in a number of industrial applications as discussed above

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